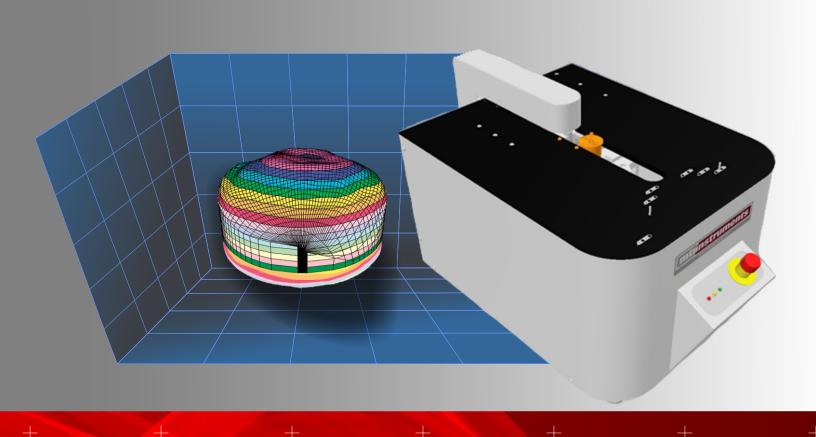


A worldwide leader in precision measurement solutions





Wafer Measurement Systems for Semiconducting and Semi-insulating Wafers

Proforma[™] 300iSA - Semi Automated Measurement Tool

THICKNESS WARP GLOBAL SITE WARP TY-LATNESS

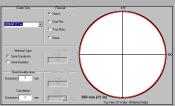
Push/Pull Probes •
Vacuum Chuck •
Teflon Coating •
Wafer Alignment Pins •

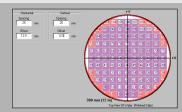
The Proforma 300iSA is a desktop, semi-automated wafer measurement system for semi-conducting and semi-insulating materials. The Proforma 300iSA delivers full wafer surface scanning forthickness, thickness variation, bow, warp, site and global flatness. User-defined and ASTM/SEMI compliant scan patterns are used to generate full 3-dimensional wafer images.

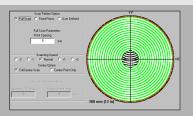




The Proforma 300iSA Controller contains all the electronics and control hardware necessary to control the Measurement Stage. It is also the interface to the external computer.

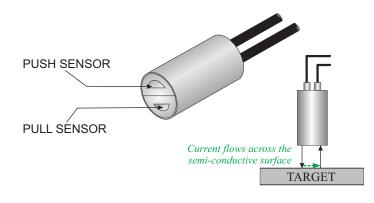






Unique Push/Pull Technology:

Two Probes built into one body



To address the needs of the semiconductor industry, MTII developed its unique "push-pull™" probe technology. In this design each probe consists of two capacitance sensors, built into one probe body. Each sensor is driven at the same voltage, however, there is a 180 degree phase shift between signals. This shift allows the current path to travel across the target surface rather than through the target to ground, eliminating any inaccuracies created by poorly grounded targets.

Additionally, highly non-conductive targets can be measured with this technology, thus allowing capacitance sensors to be used on semi-insulating and semi-conducting targets.

Proforma[™] 300iSA Features

- Non-contact full wafer scanning
- 3-D mapping of thickness and shape
- Measures semiconducting and semi-insulating wafers
- Standard Windows based user interface

- Powerful software and graphics package
- Customized data reporting
- Upgradeable to fully automated system
- Up to 1000 μm measurement range
- Remote data analysis and recipe creation

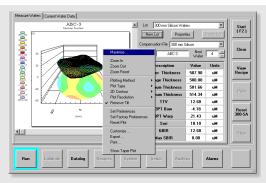
Proforma[™] 300iSA - Semi Automated Measurement Tool-

Customized data reporting, multi-format data export and full network capability allows easy access to your process information from anywhere on your network. The quick and easy to use Windows® - based control system performs complex data analysis and provides output in tabular and 3-D graphical formats which can be exported to spreadsheet and word processing programs.

The systems come preset for SEMI standard wafer diameters, with the ability to add custom wafer parameters if required. Each measurement and system parameter is selected from the user-friendly software interface.

Parameters can be modified and data recalculated without the need to rescan the wafer, allowing "what-if" engineering analysis. In addition to the powerful measurement capabilities of the standard system, an optional software package can be added for determination of wafer stress.

Able to measure as-cut, lapped, etched, polished or patterned wafers, the Proforma™ 300iSA provide fast, accurate information about your process.



perator: leasurement D leasurement T		or	Let Number: 150 mm Test Lot Recipe: Standard 150 mm AS-CUT wafers					Passed: Failed: Yield:	9 0 100.0 %
Wafer Number	Wafer ID	Center Thickness (µm)	Average Thickness (µm)	Minimum Thickness (µm)	Maximum Thickness (jum)	TTV (µm)	Bow (sm)	Warp (µm)	Sori (µm)
	Low Limit High Limit								
1	Wafer#1	710.31	709.72	708.35	711.17	2.82	-1.02	2.39	1.71
2	Wafer#2	710.10	709.73	708.41	711.13	2.72	-0.11	2.17	1.67
3	Wafer#3	709.89	709.79	708.36	711.18	2.82	-0.45	2.24	1.52
4	Wafer #4	709.69	709.78	708.30	711.19	2.89	-0.20	1.94	1.48
5	Wafer#5	709.48	709.93	708.30	711.17	2.87	-0.60	2.14	1.83
6	Wafer#11	709.27	709.65	708.29	711.20	2.91	0.31	2.17	1.48
7	Wafer#12	709.06	709.92	708.32	711.18	2.86	0.64	1.85	1.91
8	Wafer#13	708.85	709.85	708.31	711.21	2.90	0.18	2.50	1.77
9	Wafer#14	708.75	709.61	708.30	711.17	2.87	0.77	2.09	1.72
	Minimum Maximum Average Std Dev	708.75 710.31 709.49 0.520	709.61 709.93 709.77 0.106	708.29 708.41 708.33 0.038	711.13 711.21 711.18 0.021	2.72 2.91 2.85 0.056	-1.02 0.17 -0.05 0.554	1.85 2.50 2.17 0.189	1.48 1.91 1.68

Proforma[™] 300iSA - Si, GaAs, Ge, SiC, InP wafers-



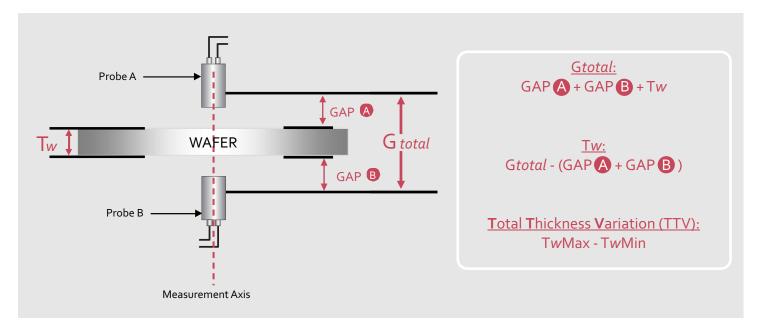
Measurement Features	Standard Range	Extended Range				
Thickness (ASTM F ₅₃₃)						
Accuracy	± 0.25 μm	± 0.50 μm				
Repeatability	o.o50 µm	o.075 μm				
TTV (ASTM F ₅₃₃)						
Accuracy	± 0.25 μm	± 0.50 μm				
Repeatability	o.o5o µm	o.075 μm				
BOW (ASTM F ₅₃₄)						
Range	± 500 μm	± 800 μm				
Accuracy	± 2.0 µm	± 5.0 μm				
Repeatability	o.750 μm	o.750 μm				
Warp (ASTM F1390)						
Range	± 500 μm	± 1500 μm				
Accuracy	± 2.0 µm	± 5.0 μm				
Repeatability	o.750 μm	o.750 μm				
Flatness - Global and Site (ASTM F1530)						
Accuracy	± 0.05 μm	± 0.15 μm				
Repeatability	o.o3 µm	o.o5 µm				

Proforma[™] 300iSA Features

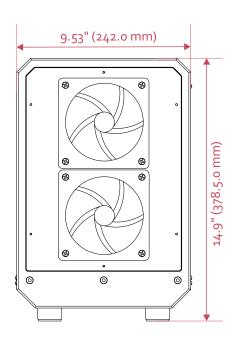
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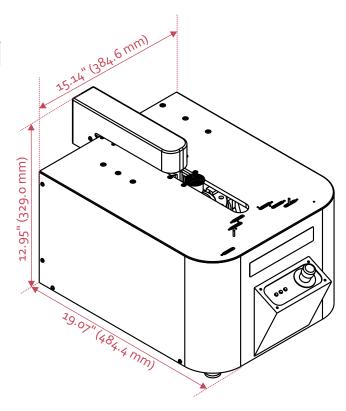
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- Customized data reporting
- Upgradeable to fully automated system
- Up to 1000 µm measurement range
- Remote data analysis and recipe creation

Proforma™ 300iSA - Measurement Principles-



Product #	Model
8000-6485	Proforma 300iSA (includes controller)
	Options
2000-2000	Silicon (Si) calibration standard
2000-2001	Gallium Arsenide (GaAs) calibration standard





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